

Docket No.: M4065.1006/P1006-A (PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Terry L. Gilton

Application No.: 10/618,824

Filed: July 14, 2003

Art Unit: 2823

For: PROGRAMMABLE CONDUCTOR

MEMORY CELL STRUCTURE AND

METHOD THEREFOR

Examiner: Hsien Ming Lee

INFORMATION DISCLOSURE STATEMENT (IDS)

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Pursuant to 37 CFR 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the reference listed on the attached PTO/SB/08. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the reference be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is filed more than three months after the U.S. filing date, OR more than three months after the date of entry of the national stage of a PCT application, AND after the mailing date of the first Office Action on the merits, whichever occurs first, but before the mailing date of a Final Office Action or Notice of Allowance (37 CFR 1.97(c)).

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Application No.: 10/618,824 Docket No.: M4065.1006/P1006-A

In accordance with 37 CFR 1.97(g), the filing of this Information Disclosure Statement shall not be construed to mean that a search has been made or that no other material information as defined in 37 CFR 1.56(a) exists. In accordance with 37 CFR 1.97(h), the filing of this Information Disclosure statement shall not be construed to be an admission that any patent, publication or other information referred to therein is "prior art" for this invention unless specifically designated as such.

It is submitted that the Information Disclosure Statement is in compliance with 37 CFR 1.98 and the Examiner is respectfully requested to consider the listed reference.

Please charge our Credit Card in the amount of \$180.00 covering the fee set forth in 37 CFR 1.17(p). Credit Card Payment Form SB-2038, with a signature from an authorized cardholder, is enclosed. The Director is hereby authorized to charge any deficiency in the fees filed, asserted to be filed or which should have been filed herewith (or with any paper hereafter filed in this application by this firm) to our Deposit Account No. 04-1073, under Order No. M4065.1006/P1006-A. A duplicate copy of this paper is enclosed.

Dated: April 15, 2004

Respectfully submitted,

Thomas J. D'Amico

Registration No.: 28,371

Peter McGee

Registration No.: 35,947

DICKSTEIN SHAPIRO MORIN &

OSHINSKY LLP

2101 L Street NW

Washington, DC 20037-1526

(202) 785-9700

Attorneys for Applicant



PTO/SB/08a/b (08-03)
Approved for use through 07/31/2006. OMB 0651-0031
U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE

Complete if Known Substitute for form 1449A/B/PTO 10/618,824-Conf. #5907 Application Number INFORMATION DISCLOSURE Filing Date July 14, 2003 STATEMENT BY APPLICANT Terry L. Gilton First Named Inventor Art Unit N/A (Use as many sheets as necessary) Not Yet Assigned Examiner Name M4065.1006/P1006-A Sheet 1 Attorney Docket Number

	U.S. PATENT DOCUMENTS										
Examiner Initials*	Cite No.1	Document Number Number-Kind Code ² (<i>if known</i>)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear						
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	NON PATENT LITERATURE DOCUMENTS								
Examiner Initials	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²						

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PTO/SB/17 (10-03)
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Complete if Known **FEE TRANSMITTAL** 10/618,824-Conf. #5907 Application Number July 14, 2003 for FY 2004 Filing Date Terry L. Gilton First Named Inventor Effective 10/01/2003, Patent fees are subject to annual revision. Examiner Name Not Yet Assigned

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SUBMITTED BY		(Complete	(Complete (if applicable))					
Name (Print/Type) Thomas	J. D'Amico			Registration No. (Attorney/Agent)	28,371	Telephone	(202) 828-2232	
Signature							April 18, 2004	

Sut	stitute for form 1449A/PTO		,	Complete if Known			
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		-		Filing Date	July 14, 2003		
٥	STATEMENT I	BY	APPLICANT	First Named Inventor	Terry L. Gilton		
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Sheet	1	of	12	Attorney Docket Number	M4065.1006/P1006-A		

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			SCLOSURE	Filing Date	July 14, 2003		
S	STATEMENT	BY	APPLICANT	First Named Inventor	Terry L. Gilton		
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^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant

¹ Applicant's unique citation designation number (optional). ² See attached Kinds Codes of USPTO Patent Documents at www.uspto.gov or MPEP 901.04. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the application number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to place a check mark here if English language Translation is attached.

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S	STATEMENT	ΓBY AP	PLICANT	First Named Inventor	Terry L. Gilton	
	_			Group Art Unit	N/A	
	(use as many	sheets as nec	essary)	Examiner Name	Not Yet Assigned	
Sheet	11	of	12	Attorney Docket Number	M4065.1006/P1006-A	

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N/A Group Art Unit (use as many sheets as necessary) Not Yet Assigned Examiner Name Attorney Docket Number M4065.1006/P1006-A Sheet of 12 12

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